# **Supply Chain Explorer**

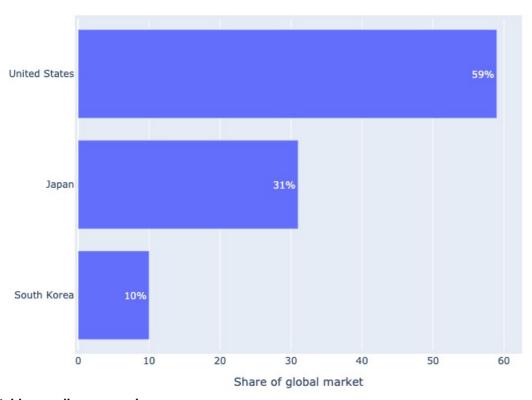
### By the Emerging Technology Observatory

This is an export from the ETO Supply Chain Explorer, available at: <a href="https://chipexplorer.eto.tech">https://chipexplorer.eto.tech</a> You can see the web version of this content at <a href="https://chipexplorer.eto.tech/?filter-choose=input-resource&input-resource=N39">https://chipexplorer.eto.tech/?filter-choose=input-resource=N39</a>.

## **Low-pressure CVD tools**

Low-pressure chemical vapor deposition tools are commonly used to deposit polysilicon, tungsten, titanium, and titanium nitride.

### **Country provision**



### Notable supplier companies

- Applied Materials United States
- · Lam Research United States
- NAURA (negligible market share) China (mainland)
- Tokyo Electron Japan